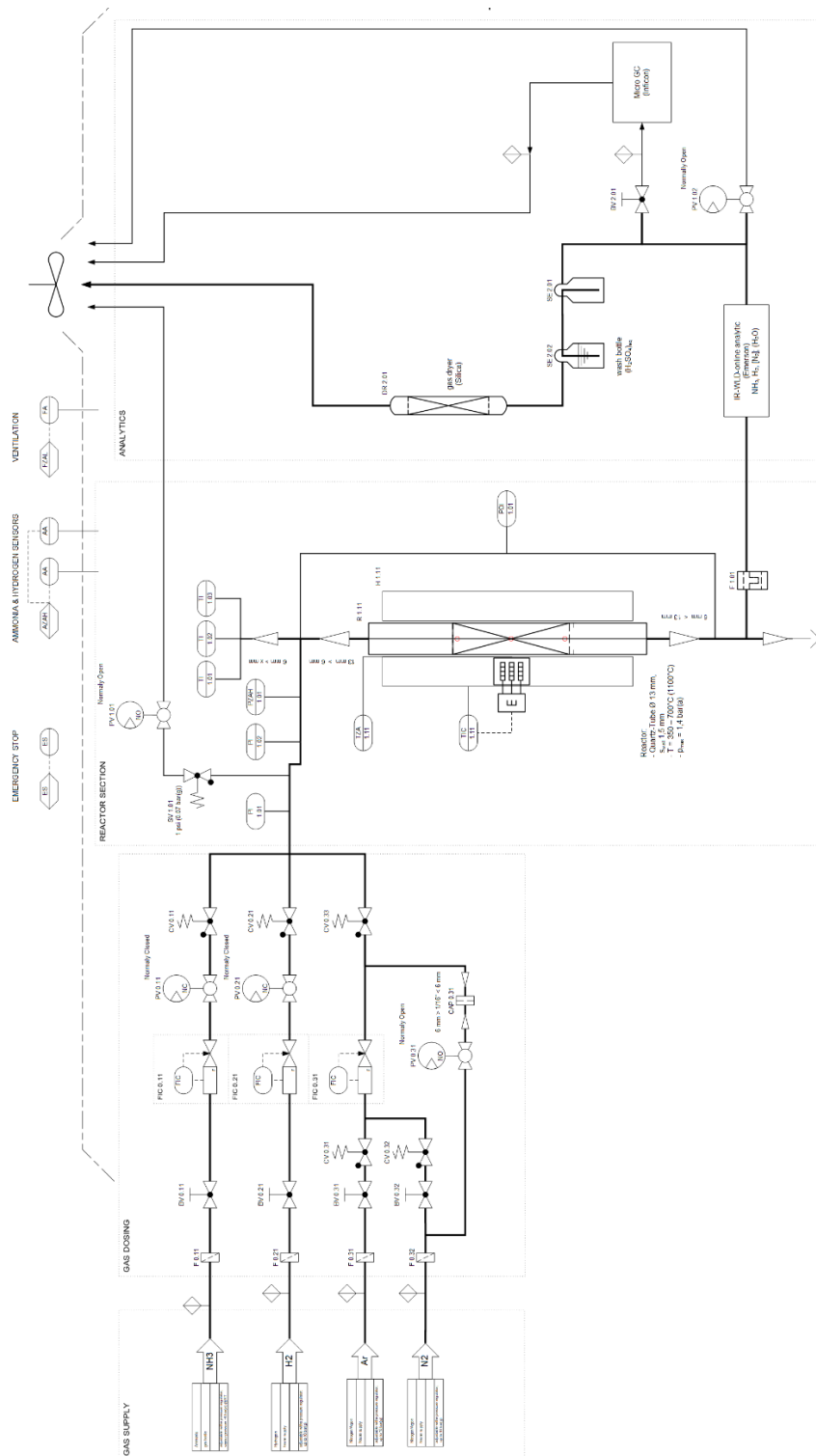


Supporting Information

Ambient Pressure Ammonia Decomposition Using Ga-Co Supported Catalytically Active Liquid Metal Solutions

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Continuous gas-phase reactor setup

A detailed flow scheme of the reactor is shown in Figure S1.

Figure S 1. R&I of the continuous gas-phase reactor used for ammonia decomposition studies.

Calculations and Equations

The weight hourly space velocity (WHSV) is defined as the ratio of the total gas flow, in our case the volume flow of pure NH₃, at standard conditions (German: Normbedingungen) 273.15 K and 1013.25 mbar (\dot{V}_N) over the catalyst mass (m_{cat}).

$$WHSV = \frac{\dot{V}_N}{m_{cat}} \quad (S 1)$$

The gas hourly space velocity (GHSV) is defined as the ratio of the total gas flow, in our case the volume flow of pure NH₃, at standard conditions (German: Normbedingungen) 273.15 K and 1013.25 mbar (\dot{V}_N) over the catalyst bed volume (V_{cat}).

$$GHSV = \frac{\dot{V}_N}{V_{cat}} \quad (S 2)$$

The catalyst bed volume V_{cat} was determined by measuring the height of the catalyst bed (h_{cat}) with a string spacing ruler (accuracy ± 0.5 mm), the inner diameter of the reactor ($d_{in,reactor}$) and the outer diameter of the inner capillary ($d_{out,capillary}$) according to the following equation:

$$V_{cat} = \frac{\pi}{4} (d_{in,reactor}^2 - d_{out,capillary}^2) \cdot h_{cat} \quad (S 3)$$

The ammonia conversion (X_{NH_3}) was calculated using the normalized molar concentrations of NH₃ (x_{NH_3}) obtained from the micro gas chromatograph.

$$X_{NH_3} = \frac{1 - x_{NH_3}}{1 + x_{NH_3}} \quad (S 4)$$

The cobalt specific H₂ productivity was defined as the released H₂ (product of X_{NH_3} with the molar ratio 1.5 between NH₃ and H₂ according to the reaction equation) multiplied with the molar flow of ammonia (product of \dot{V}_N , NH₃ density at standard condition ρ_{NH_3} , through molar mass M_{NH_3}) and divided by the utilized Co mass m_{Co} (product m_{cat} and Co mass loading w_{Co}):

$$\text{specific H}_2 \text{ productivity} = 1.5 \cdot X_{NH_3} \cdot \frac{\dot{V}_N \cdot \rho_{NH_3}}{M_{NH_3}} \cdot \frac{1}{m_{cat} \cdot w_{Co}} \quad (S 5)$$

Analogously, H₂ productivities specific to other metals were calculated.

Materials

Material / product name	CAS nr.	Batch nr.	Purity	Supplier
β -SiC / SiC3-E2-HP	409-21-2	SD0222C3W	> 99.9%	ACM GmbH
β -SiC / SiC4-E2-HP	409-21-2	SD0222A3W	> 99.9%	ACM GmbH
Ga	7440-55-3		99.9999%	ThermoScientific
Co(NO ₃) ₂ · 6H ₂ O / Cobalt(II) nitrate hexahydrate	10026-22-9	M16D012	98-102%	Alfa Aesar
Ni(DME)Cl ₂ / nickel(II) chloride ethylene glycol dimethyl ether	29046-78-4		98%	Sigma-Aldrich
CuCl ₂ / copper(II) chloride	7447-39-4		≥ 99.995%	Sigma-Aldrich
Propan-2-ol / isopropanol	67-63-0		≥99.3%	Jäkle Chemie (Germany)
NH ₃ / Ammonia 5.0	7664-41-7		≥ 99,999%	Air Liquide Deutschland GmbH
H ₂ / ALPHAGAZ™1 Hydrogen (5.0)	1333-74-0		≥ 99,999 mol%	Air Liquide Deutschland GmbH
N ₂ / ALPHAGAZ™1 Nitrogen (5.0)	7727-37-9		≥ 99,999 mol%	Air Liquide Deutschland GmbH
Ar / ALPHAGAZ™1 Argon (5.0)	7440-37-1		≥ 99,999 mol%	Air Liquide Deutschland GmbH

Materials Synthesis

Method for Monometallic Co on SiC

Incipient wetness impregnation was used to prepare monometallic Co on SiC catalysts.

Aiming for 0.07 wt% (ICP-AES: 0.05 wt%): 0.0518 g of Co(NO₃)₂ · 6H₂O was weighed and dissolved in 30 mL of de-ionized water. The Co solution was slowly added dropwise to 15.0052 g of SiC4 (250-500 μm), until the support was slightly wet.

Aiming for 1 wt% Co loading (ICP-AES: 1.05 wt%): 0.3965 g of Co(NO₃)₂ · 6H₂O was weighed and dissolved in 15 mL of de-ionized water. The Co solution was slowly added dropwise to 7.9170 g of SiC4 (250-500 μm), until the support was slightly wet.

The mixture was then rotated at 250 rpm for 10 min before drying at 100 °C for 30 min.

The resultant Co-SiC sample was then calcined using the following procedure:

The sample was heated from room temperature to 150 °C (at a rate of 2 °C min⁻¹) and then held at 150 °C for 30 min; thereafter heated from 150 °C to 600 °C (at a rate of 2 °C min⁻¹) and then held at 600 °C for 180 min prior to returning to room temperature.

Method for SCALMS catalyst

The SCALMS catalysts were prepared by physical dispersion of the matrix metal Ga, followed by the deposition of the dispersion on SiC3 support.

The first step includes the deposition of Ga on the support. A Ga nugget of about 1.00 g was melted and dispersed in 100 mL of isopropanol via ultrasonication. Ultrasonication was carried out at 40 °C using Branson 450D sonicator (400 W) equipped with a 1/4" tip at 80% amplitude (power input 80 W) for 30 min. After sonication, the emulsion was added to a defined amount of SiC (~13.00 g). Then, the solvent was slowly evaporated in a rotary evaporator at 50 °C. The obtained solid was calcined at 450 °C for 2 h.

For the second step of the preparation procedure the resulting Ga/SiC was suspended in 50 mL of isopropanol and solution of the corresponding amounts of metal precursors, namely Cobalt(II) nitrate hexahydrate, nickel(II) chloride ethylene glycol dimethyl ether, and copper(II) chloride, dissolved in 10 mL 20_{v/v}% water in isopropanol, was added in order to achieve the desired Ga/secondary metal ratio. The solvent was then slowly evaporated in a rotary evaporator at 50 °C. The obtained solid was calcined at 500 °C for 2 h.

Mercury Intrusion Porosimetry

Mercury intrusion porosimetry was performed on a Poremaster60 (Anton Paar QuantaTec, FL, USA). Triple distilled mercury (purity 99.9995%) was purchased from GMR Gesellschaft für Metallrecycling GmbH, Leipzig. All measurements were performed using the Autospeed mode with motor speed 1. Outgassing of the samples was done at ambient temperature using the vacuum procedure in the experimental procedure. Data evaluation was done using the corresponding software (PoroWin, Anton Paar Quantatech, FL, USA) utilizing the Washburn equation with 480 mN m^{-1} as the liquid vapor surface tension of mercury and 140° as the contact angle in between mercury and SiC. Figure S 3 shows the cumulative intrusion curves including the first intrusion step, associated with powder/particle compression. The pore size distributions are shown in Figure S 2.

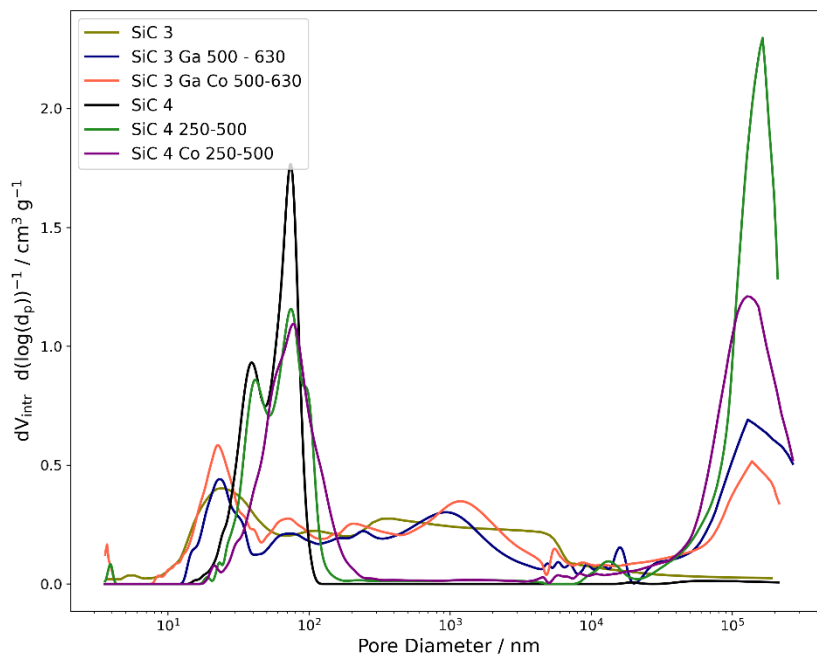


Figure S 2: Differential pore size distributions for SiC support (SiC3 whole pellets, SiC4 crushed pellets sieve fractions 250 - 500 μm and 500 - 630 μm), $\text{Ga}_{59}\text{Co}/\text{SiC3}$ (crushed pellets sieve fractions 500 - 630 μm), $1.05 \text{ wt}\% \text{ Co}/\text{SiC4}$ (crushed pellets sieve fraction 250 - 500 μm) and $\text{Ga}/\text{SiC3}$ (crushed pellets sieve fractions 500 - 630 μm)

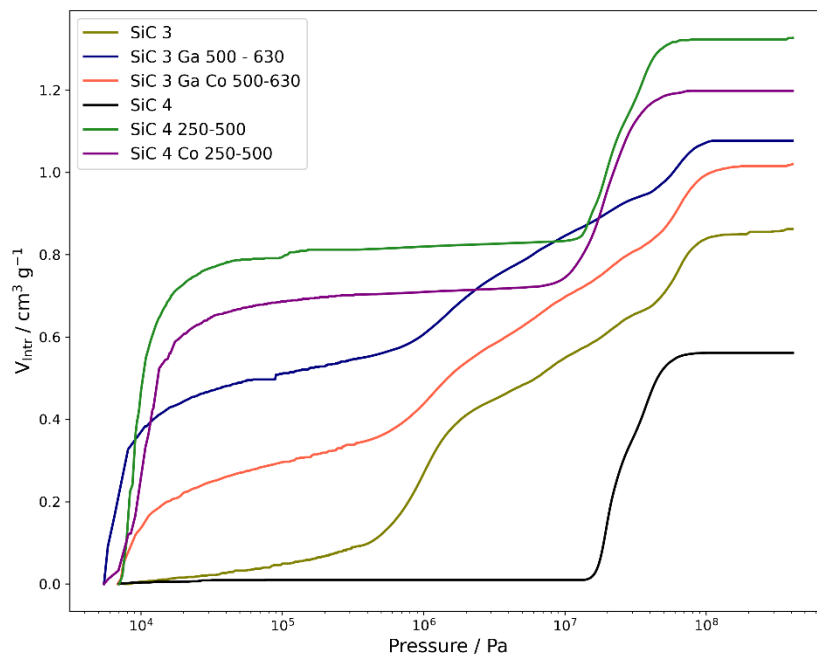


Figure S 3: Cumulative mercury intrusion volume over applied total pressure for SiC support (SiC3 whole pellets, SiC4 crushed pellets sieve fractions 250 - 500 μm and 500 - 630 μm), Ga59Co/SiC3 (crushed pellets sieve fractions 500 - 630 μm), Co/SiC4 (crushed pellets sieve fraction 250 - 500 μm) and Ga/SiC3 (crushed pellets sieve fractions 500 - 630 μm)

Nitrogen Sorption

The N_2 sorption full isotherms (see Figure S 4 and Figure S 5) were measured with a TriStar II Plus (Micromeritics GmbH) after predrying the samples at 573 K for at least 12 h. Data acquisition, calculations and model fitting were done with the corresponding manufacturer software TriStar II Plus version 3.02. Data analysis based on the multipoint BET model were used to obtain information about the specific surface area and are shown in Table S 1.

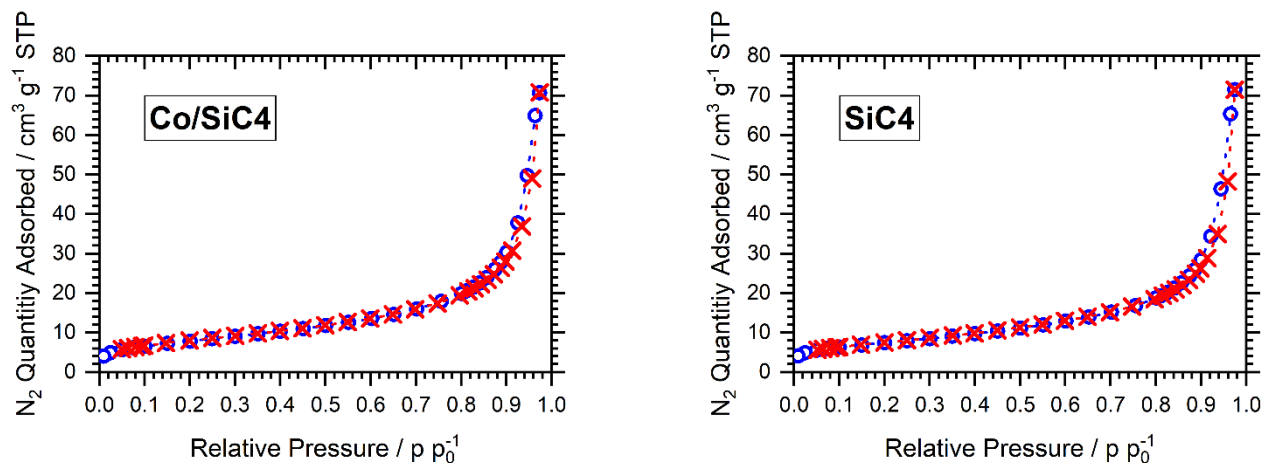


Figure S 4: Adsorption (red cross x) and desorption (blue open circle \circ) isotherms for 1.05 wt% Co on SiC4 (sieve fraction 250 - 500 μm , left diagram) before reaction in comparison with the untreated raw SiC4 (sieve fraction 250 - 500 μm , right diagram). Analysis adsorptive N_2 , analysis bath temperature 77.3 K, saturation pressure p_0 993 mbar (Co/SiC4) and 992 mbar (SiC3).

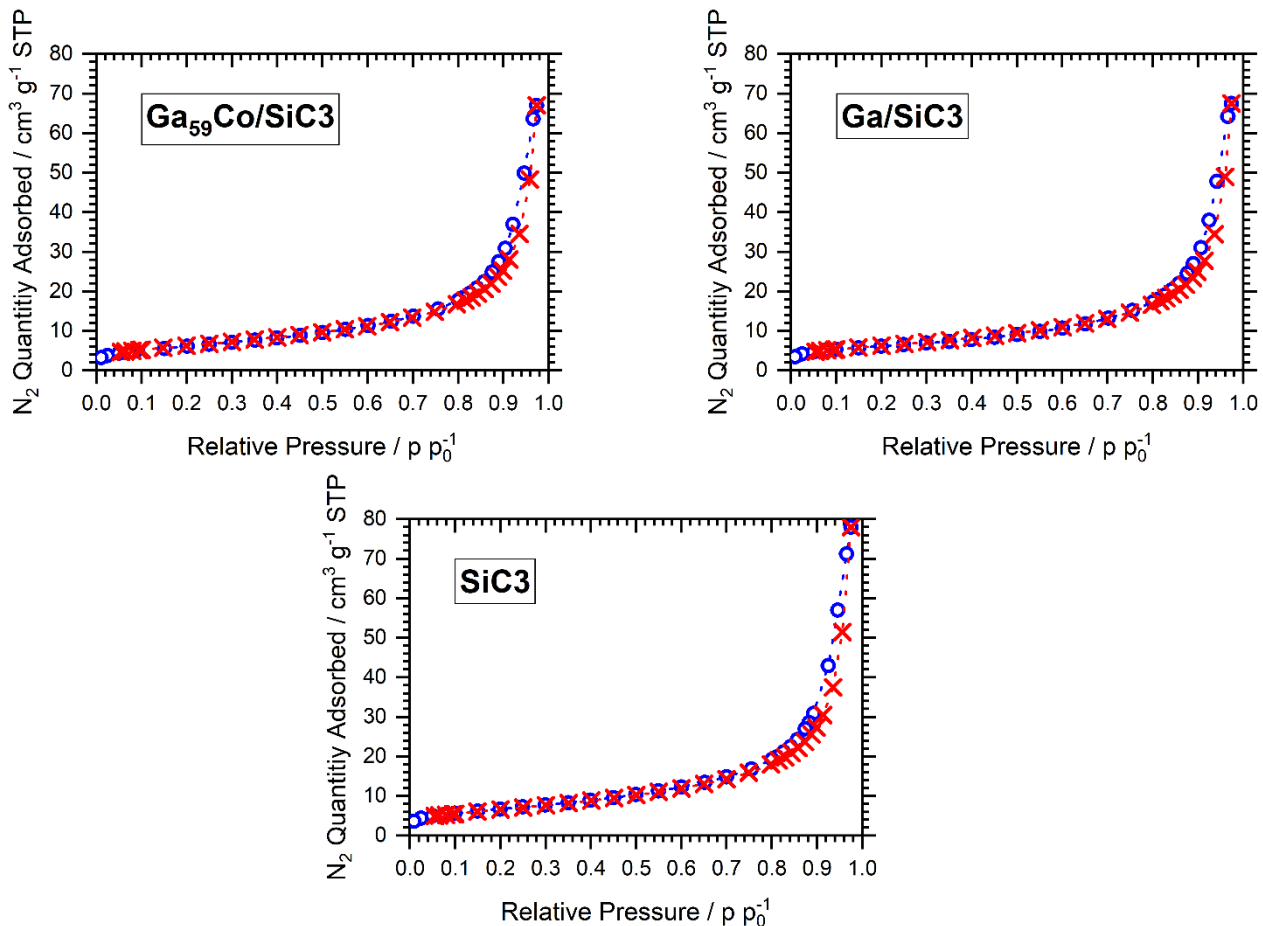


Figure S 5: Adsorption (red cross x) and desorption (blue open circle o) isotherms for Ga_{59}Co on SiC3 (sieve fraction 500 – 630 μm , upper left diagram) and Ga on SiC3 (sieve fraction 500 – 630 μm , upper right diagram) before reaction in comparison with the untreated raw SiC3 pellets support. Analysis adsorptive N_2 , analysis bath temperature 77.3 K, saturation pressure p_0 991 mbar ($\text{Ga}_{59}\text{Co}/\text{SiC3}$), 992 mbar ($\text{Ga}/\text{SiC3}$) and 1000 mbar (SiC3).

Table S 1: Material properties retrieved by N_2 sorption and Hg porosimetry.

Material	Particle size* / μm	Surface area** / $\text{m}^2 \text{g}^{-1}$	Hg porosimetry*** / $\text{cm}^3 \text{g}_{\text{support}}^{-1}$			Total intrusion volume
			5 – 50 nm	< 5 μm	> 10 μm	
SiC3	-	24.01 ± 0.04	0.21	0.78	0.06	0.86
$\text{Ga}_{59}\text{Co}/\text{SiC3}$	500 - 630	22.87 ± 0.02	0.14	0.53	0.52	1.08
$\text{Ga}/\text{SiC3}$	500 - 630	22.54 ± 0.04	0.21	0.68	0.31	1.02
SiC4	-		0.22	0.55	0.01	0.56
SiC4	250 - 500	27.16 ± 0.02	0.17	0.51	0.81	1.33
$\text{Co}/\text{SiC4}$	250 - 500	29.29 ± 0.03	0.09	0.50	0.69	1.20

*sieve fraction after crushing pellets **by multipoint BET ***separated by intra-particle pore diameters

Scanning Transmission Electron Microscopy – Energy Dispersive X-Ray Spectroscopy (STEM -EDXS)

A Talos F200i from Thermo Fisher Scientific was used to record images with a high angle annular dark field (HAADF) STEM detector. The microscope is equipped with a Schottky emitter, two Bruker XFlash 6T-100EDS detectors and was operated at 200 kV acceleration voltage. Data evaluation was performed in the software Velox.

The samples were prepared by grinding the catalyst in a mortar to receive a fine powder, which was dispersed in a mixture of ethanol and isopropanol 50:50 (volume) within a rolled rim glass and sonicated for at least 5 min. The dispersion was drop-casted on a TEM grid placed on a clean filter paper and dried in air on ambient conditions. The TEM-grids used were distributed by Plano GmbH and manufactured by Quantifoil Micro Tools GmbH as a gold grid (mesh size 300) with a holey carbon film. The measurements and images for samples with 0.05 wt% Co/SiC₄ are not shown, as no Co was detectable in the samples before or after the reaction due to the low metal loading. Therefore, Co signals get lost in the background noise.

As the smallest clusters we could distinguish in the 1.05 wt% Co/SiC₄ samples (Figure S 6) were about 5 nm in diameter, we can expect the Co in the 0.05 wt% samples to be evenly distributed in SiC or to be in clusters significantly smaller than 5 nm.

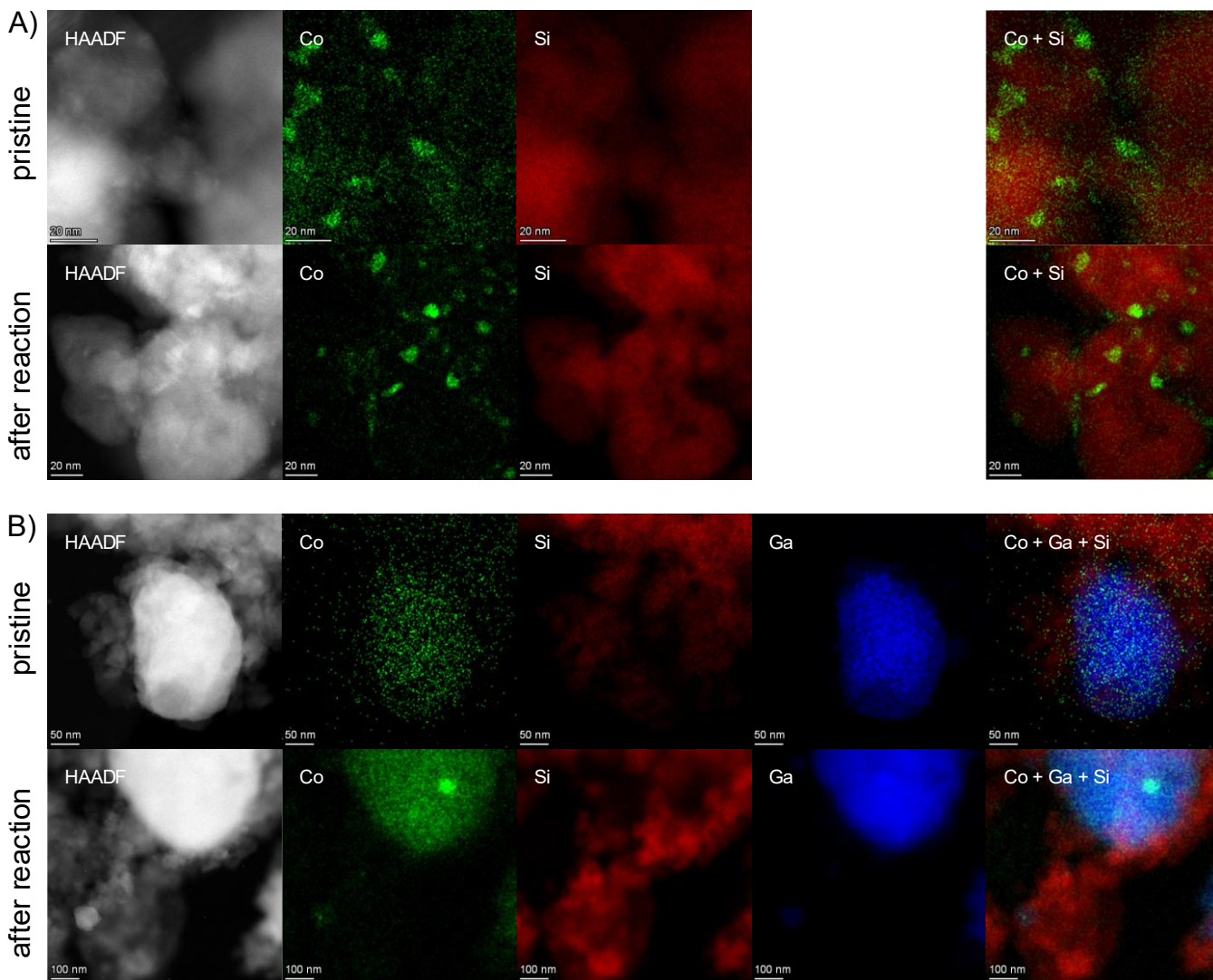


Figure S 6: STEM-EDX spectrum imaging of A) Co/SiC₄ catalyst containing 1.05 wt% Co only. Individual particles are easily identified both in the pristine sample and after cycling. B) Ga₅₉Co/SiC₃ catalyst containing Ga and Co. Note that Co here is always associated with Ga.

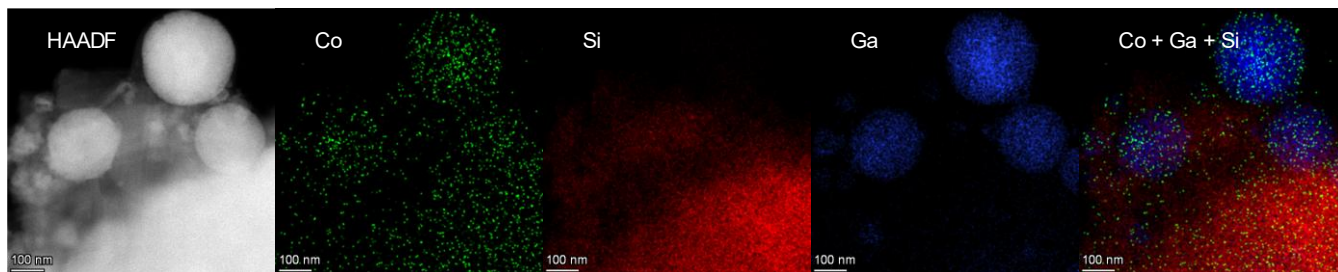


Figure S 7: STEM-EDX spectrum imaging of $\text{Ga}_{59}\text{Co}/\text{SiC}_3$ catalyst after the reaction containing Ga and Co. Here the Ga-droplets were exfoliated with adhesive tape to isolate Ga-Co droplets from the structure. The tape used was a conductive double sided adhesive carbon tape (MSPP15-000512) supplied by VWR International GmbH. Note that again Co here is always associated with Ga and no isolated Co particles were observed.

Scanning Electron Microscopy - Energy Dispersive X-Ray Spectroscopy (SEM-EDXS)

Scanning Electron Microscopy (SEM) analyses were carried out using a Phenom Desktop SEM (full backscattered electron detector (BSD), 15 kV voltage). The particles were deposited directly on a conductive sticky carbon tape (MSPP15-000512) supplied by VWR International GmbH and dried under ambient conditions before measurement. Figure S 8 shows an exemplary SiC_3 particle coated with Ga_{59}Co droplets. The droplets enter pores and cavities at the surface with diameters of $10\ \mu\text{m}$ and above.

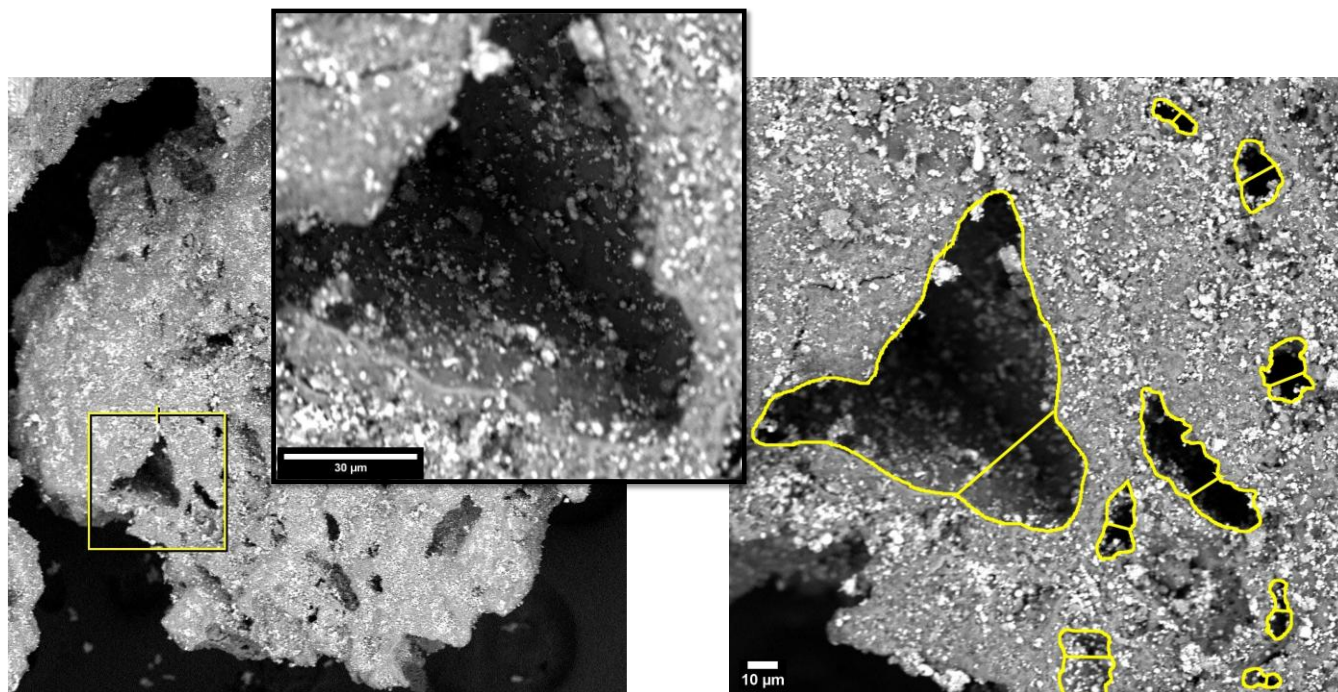


Figure S 8: Exemplary SEM images (BSD Full) of an $\text{Ga}_{59}\text{Co}/\text{SiC}_3$ catalyst with highlighted pores and cavities containing metal droplets.

Inductively Coupled Plasma Atomic Emission Spectroscopy (ICP-AES)

The Ga and Co loading and the corresponding Ga:Co-ratios of the SCALMS were determined by inductively coupled plasma atomic emission spectroscopy (ICP-AES) using a Ciros CCD (Spectro Analytical Instruments GmbH). The same was done for the Ni and Cu. The solid samples were ground with a mortar prior to digestion in solution of concentrated HCl:HNO₃:HF (volumetric ratio of 3:1:1) using microwave heating up to 220 °C for 40 min.

The instrument was calibrated with standard solutions of Co, Ni, Cu and Ga prior to the measurements.

X-Ray diffraction (XRD)

Powder X-ray diffraction (XRD) measurements were performed on a X'Pert Pro by Malven Panalytcs to determine the solid-state structure of the prepared, mortar grounded materials. The measurements were carried out in angles 2θ of 10–90 °, a scanning speed of 0.02°/s, a step size of 0.015° and 100 s time per step. Cu-Kα was used as the radiation source and X'Celerator as the detector. The data was processed utilizing X'Pert Highscore Plus and compared to simulated reflexes from the inorganic crystal structure database (ICSD).

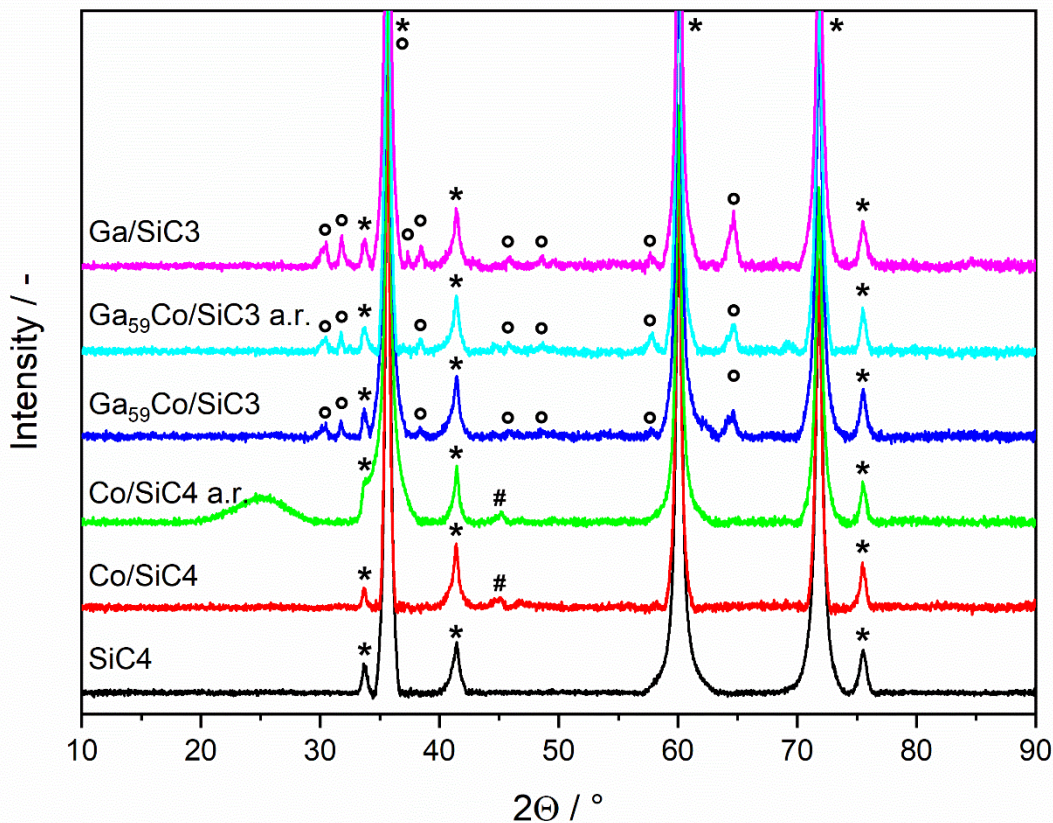


Figure S 9: XRD patterns of the samples (bottom to the top) SiC4 (black), 1.05 wt% Co on SiC4 before (red) and after reaction (green), Ga₅₉Co on SiC3 before (dark blue) and after reaction (cyan) and Ga on SiC (pink). The symbols refer to dominant reflexes for SiC/Moissanite 3C (star: *, ICSD-reference code 98-016-4973), gallium oxide β (circle °, ICSD-reference code 98-003-4243). The weak reflex at close to 45° observed for monometallic Co on SiC systems (hashtag: #) could refer to dicobalt silicide (ICSD-reference code 98-005-2281), but could not be clarified due to the low reflex intensity.

The XRD data give no hint for a Ga-Co intermetallic structure, but as the Co related reflex for the monometallic Co on SiC system with 1.05 wt% Co loading 2θ at about 45° was low in intensity, Co related reflexes for the SCALMS system with 0.04 wt% Co loading are expected to be not measurable in this setup. Therefore, the measurement for 0.05 wt% Co on SiC was skipped. No shifts in the Ga related reflexes for the Ga₅₉Co/SiC3 were observable.

Blank activity quartz reactor and supporting materials

A systematic approach was chosen to verify the blank activity of the quartz reactor tube, quartz capillary, quartz wool, activated carbon and SiC support, as well as to check the blank activity of pure gallium. The quartz reactor was loaded with 0.3 g of quartz wool, 0.3 g of activated carbon, and 1.05 g of SiC support, loaded with 4.27 wt% Ga. The system was reduced under a gas flow of a 3:1 H₂:N₂ mixture at up to 640 °C. The gas was switched to an undiluted NH₃ gas flow in the range of 190-60 ml_N min⁻¹ and the temperature was stepwise increased up to 582 °C (see Figure S 10).

Within the first 30 min, an apparent conversion, decreasing over time, was observable and is accounted to remnants of the reduction gas being flushed out. Up to temperatures of 582 °C and flowrates down to 60 ml_N min⁻¹ (equals a WHSV of 3 l_N g_{cat}⁻¹ h⁻¹) stayed below the threshold value of 0.05%. No N₂ was detectable after 0.5 h TOS during the experiment. H₂ signals were negligible low. Therefore, the combined activities of the Ga on SiC, quartz components, and activated carbon are negligible within the parameter ranges of the presented experiments. The blank activities of the isolated components are consequently also considered negligible, and no influence on the accuracy of the experiments is anticipated.

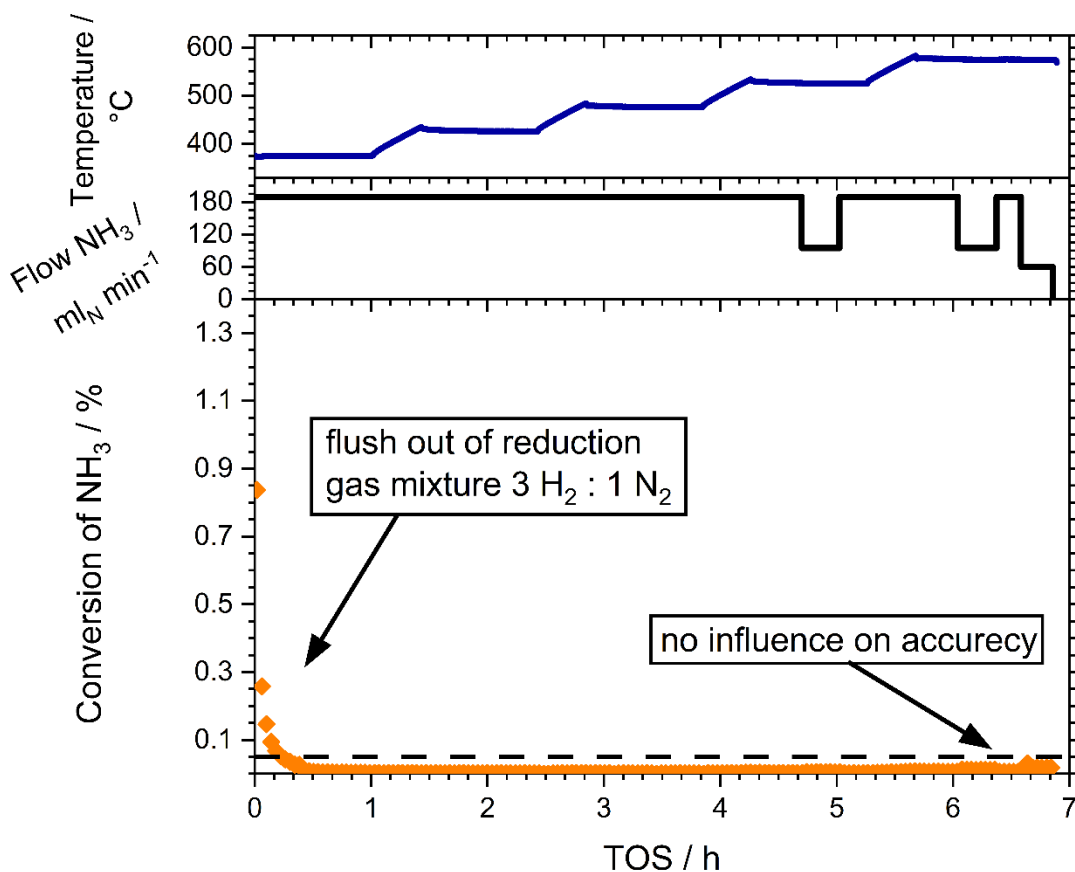


Figure S 10: Catalyst temperature (top; **blue line**), NH₃ flowrate (middle; **black line**), and NH₃ conversion for Ga on SiC as blank conversion test and as reference (bottom, **orange diamond** ♦, $m_{\text{cat}} = 1.05 \text{ g}$, $V_{\text{cat}} = 2.2 \text{ ml}$, $w_{\text{Ga}} = 4.27 \text{ wt\%}$, $\text{WHSV} = 3\text{-}11 \text{ l}_{\text{N}} \text{ g}_{\text{cat}}^{-1} \text{ h}^{-1}$, $p_{\text{total}} = 1 \text{ bar(a)}$, $T_{\text{cat,max}} = 582 \text{ °C}$). The dashed line indicates the 0.05% conversion threshold below which no influence on the accuracy of the experiment is claimed.

Extended Co-specific H₂ productivity data

A comparison of Co-specific H₂ productivity over temperature for a Ga₅₉Co/SiC3 SCALMS (0.04 wt% Co-loading) with two monometallic Co/SiC4 catalysts (1.05 wt% and 0.05 wt% Co-loading) is given in Figure S 11. Noteworthy is the up to 9 times higher productivity of the SCALMS catalyst at comprising temperatures of 550 °C and 527 °C with 487 to 54 g_{H₂} g_{Co}⁻¹ h⁻¹ and 198 to 21 g_{H₂} g_{Co}⁻¹ h⁻¹ respectively. Between the two monometallic Co catalysts at 550°C a factor of 1.6 in the Co specific productivity was observable, with the higher loaded catalyst (1.05 wt%) being more active. This observation can be explained by the bigger Co clusters in the 1.05 wt% Co/SiC4 confirmed in the STEM-EDXS images (Figure S 6).

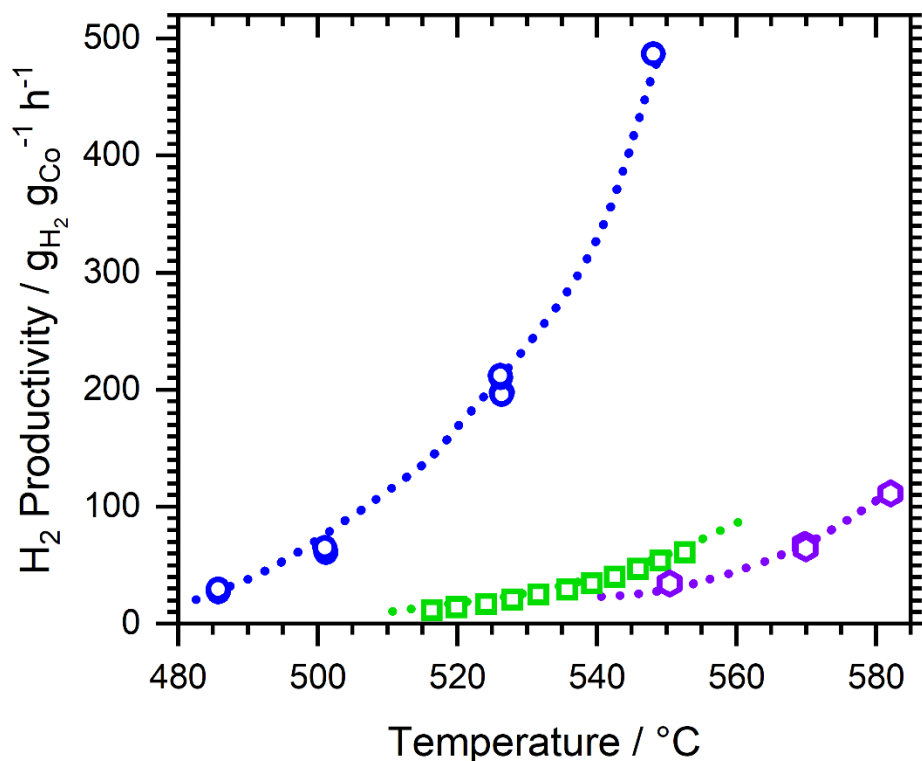


Figure S 11: H₂ productivity specific to the Co mass at 5 ± 0.5% NH₃ conversion at different catalyst temperatures for Ga₅₉Co/SiC (blue circle ○, m_{cat} = 1.00 g, V_{cat} = 1.8 ml, w_{Co} = 0.04 wt%, w_{Ga} = 3.12 wt%, WHSV = 2-29 l_N g_{cat}⁻¹ h⁻¹, p_{total} = 1 bar(a)), 1.05 wt% Co/SiC (light green square □, m_{cat} = 0.25 g, V_{cat} = 0.73 ml, w_{Co} = 1.05 wt%, WHSV = 8-58 l_N g_{cat}⁻¹ h⁻¹, p_{total} = 1 bar(a)), and 0.05 wt%Co/SiC (purple hexagon ◑, m_{cat} = 1.00 g, V_{cat} = 1.5 ml, w_{Co} = 0.05 wt%, WHSV = 3-9 l_N g_{cat}⁻¹ h⁻¹, p_{total} = 1 bar(a)). Dotted lines to guide the eye.

Stabilisation and saturation of Ga₅₉Co SCALMS

Figure S 12 shows the deactivation of a Ga₅₉Co SCALMS catalyst over 90 h of constant ammonia flow beyond 247 h TOS, as indicated by changes in NH₃ conversion and the corresponding H₂ productivity specific to the Co mass. After an initial flushing with H₂, the system was maintained at a constant volume flow of 10 L_N min⁻¹ at 579 ± 1 °C. The system showed a conversion of 11.7 ± 0.0% at 247 h TOS, followed by a steady deactivation (deactivation rate 0.2 % h⁻¹) to reach a conversion of 9.5 ± 0.0% after 12 h. The slope then steadily decreased, stabilizing at a conversion of 8.4 ± 0.0% after 30 h (277 h TOS). We attribute this curve profile to a classical adsorption system that saturates over time; in this case, water is adsorbing at the SCALMS system. A breakthrough of water could not be observed because the water content of the pure ammonia was below the detection limit of the analytics used.

The H₂ productivity of the system decreased from initially 357 g_{H₂} g_{Co}⁻¹ h⁻¹ to 257 g_{H₂} g_{Co}⁻¹ h⁻¹. This corresponds to an activity loss of approximately 30 %. The activity of the SCALMS system remains significantly higher than all activities observed for monometallic Co systems. This highlights the fundamentally different nature of the SCALMS system compared to monometallic systems.

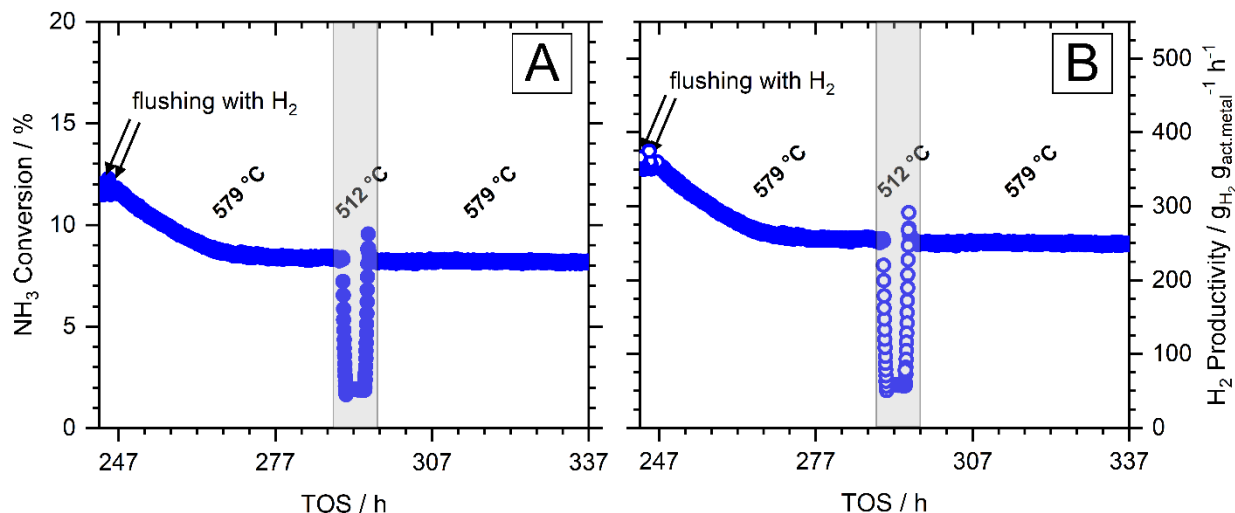


Figure S 12: NH₃ conversion (Figure S 12A, filled symbols) and H₂ productivity specific to the Co mass (Figure S 12, hollow symbols) over time on stream (TOS) for Ga₅₉Co/SiC SCALMS (blue circle ●, m_{cat} = 1.00 g, V_{cat} = 1.8 ml, w_{Co} = 0.04 wt%, w_{Ga} = 3.12 wt%). Reaction conditions: T_{cat} = 579 °C, p_{total} = 1 bar(a), WHSV = 10 l_N g_{cat}⁻¹ h⁻¹.